

STION systems Technical Bulletin

 □ Place a copy of this bulletin in the front of each Blueprints Manual. □ Redline drawings as needed and include a TB reference note. □ Document TB implementation schedule request and completion: 							TB Number: Date Issued:		098 Nov10, 2014	
Date Scheduled	Date Completed					Expiration Date:		none		
Completed by (name)										
Subject/Key Words:		CIP, Advanced Phos Control (APC): Avoid DIW dehydration and wafer cross slotting								
Classification:			Informational	۵	Mandatory		Safety Alert	☐ Preventive	e Maintenance Impact	
			Warranty Impact		Purchase Parts			For Parts expires en ordering NC p	// Reference of the courts.	
Application:		Gama PRM modules having APC DIW Concentration Control								
Parts/Documents:		Applicable hardware kits: 239925-001, 239924-001, or 240124-001 plus APC feature specific software.								
Attachments:		r	none							
<u>Issue</u> :	APC enha Nitric DIW attrib	Continual Improvement Process initiatives have been driven to optimize the APC DIW concentration feature issued on new tool and product enhancement purchases. Nitride Etch processes control algorithm has been analyzed to understand DIW dehydration phenomena and associated bath turbulence which is attributed to periodic wafer cross slotting.								
Inspection:	Systems affected by project number: 0334-01*, 0343-01, 0343-06, 1101-01, 1205-03*, 1309-01, 1334-01, 1593-01, 1609-02* (* solution implemented and validated)									
Solution:	APC software enhancements: to activate DIW spiking during mix time to avoid dehydration of the phosphoric bath and to disable DIW spiking during conditions which will lead to over hydration.									
	A hardware kit will also be issued and installed to ensure position of the ASG sensor tube for stable readings.									
	Akrion Systems field service managers will contact affected customers to make arrangements for installation of these CIP upgrades.									